



ELECTRONIC COPY

LABORATORY GROWN DIAMOND REPORT

August 26, 2026	
IGI Report Number	LG830625197
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	PEAR MODIFIED BRILLIANT
Measurements	10.57 X 6.83 X 4.07 MM

GRADING RESULTS

Carat Weight	2.05 CARATS
Color Grade	FANCY YELLOW
Clarity Grade	VS 1

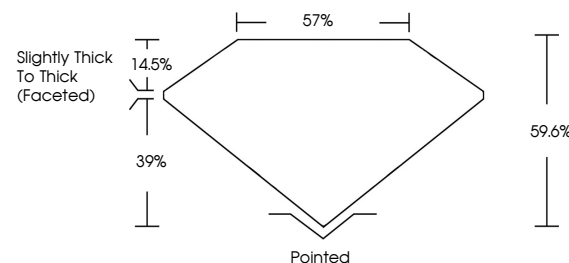
ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	15 LG830625197

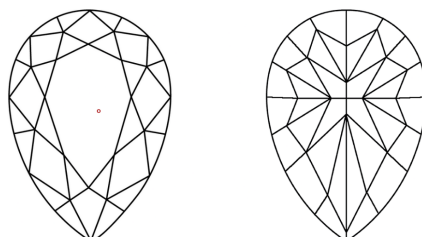
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.

LG830625197
Report verification at iqi.org

PROPORTIONS



CLARITY CHARACTERISTICS



KEY TO SYMBOLS

Red symbols indicate internal characteristics.
Green symbols indicate external characteristics.



Sample Image Used

COLOR

D E F G H I J Faint Very Light Light

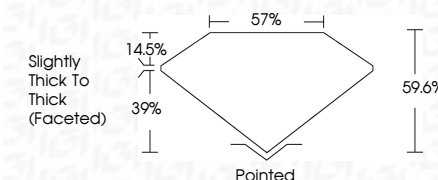
CLARITY

FL	IF	VVS ¹⁻²	VS ¹⁻²	SI ¹⁻²	I ¹⁻³
Flawless	Internally Flawless	Very Very Slightly Included	Very Slightly Included	Slightly Included	Included

LABORATORY GROWN DIAMOND REPORT



August 26, 2026	
IGI Report Number	LG830625197
Description	LABORATORY GROWN DIAMOND
Shape and Cutting Style	PEAR MODIFIED BRILLIANT
Measurements	10.57 X 6.83 X 4.07 MM
GRADING RESULTS	
Carat Weight	2.05 CARATS
Color Grade	FANCY YELLOW
Clarity Grade	VS 1



ADDITIONAL GRADING INFORMATION

Polish	EXCELLENT
Symmetry	EXCELLENT
Fluorescence	NONE
Inscription(s)	 LG830625197
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process.	



© IGI 2020, International Gemological Institute

FD - 10 20



THIS DOCUMENT WAS PRODUCED WITH THE FOLLOWING SECURITY MEASURES: SPECIAL DOCUMENT PAPER, INK SCREENS, WATERMARK, BACKGROUND DESIGNS, HOLOGRAM AND OTHER SECURITY FEATURES NOT LISTED AND DO EXCEED DOCUMENT SECURITY INDUSTRY GUIDELINES

August 26, 2026
LGI Report No LG8
PEAR MODIFIED BR

MM	2.05 CARATS	VS 1	Pointed
	FANCY YELLOW	59.6%	EXCELLENT
		57%	EXCELLENT
	Slightly Thick To Thick (Faceted)		NONE
			4.69 L G899025197

Comments:
This Laboratory Grown Diamond was
created by Chemical Vapor Deposition